

NANO EXPRESS

Open Access



Calculation of Energy Diagram of Asymmetric Graded-Band-Gap Semiconductor Superlattices

Liubomyr S. Monastyrskii, Bogdan S. Sokolovskii* and Mariya P. Alekseychik

Abstract

The paper theoretically investigates the peculiarities of energy diagram of asymmetric graded-band-gap superlattices with linear coordinate dependences of band gap and electron affinity. For calculating the energy diagram of asymmetric graded-band-gap superlattices, linearized Poisson's equation has been solved for the two layers forming a period of the superlattice. The obtained coordinate dependences of edges of the conduction and valence bands demonstrate substantial transformation of the shape of the energy diagram at changing the period of the lattice and the ratio of width of the adjacent layers. The most marked changes in the energy diagram take place when the period of lattice is comparable with the Debye screening length. In the case when the lattice period is much smaller than the Debye screening length, the energy diagram has the shape of a sawtooth-like pattern.

Keywords: Graded-band-gap semiconductors, Energy diagram, Superlattices, Multilayer structures

PACS: 73.20.-r, 71.20.-b, 73.21.Ac, 73.40.Lq

Background

The graded-band-gap semiconductors have attracted the attention of scientists since the year 1957 when H. Kroemer puts forward the idea about quasioelectric and quasio-magnetic fields [1] which, in contrast with the conventional fields, act in a different way upon electrons and holes. The presence of such fields is a unique feature of semiconductors with spatially nonhomogeneous composition that leads to formation in these semiconductors in a number of properties [2] which are of interest for many practical applications, particularly for fabrication of efficient solar cells [3, 4]. The strength of the quasioelectric field is proportional to the gradient of composition, and achieving its large and constant value is possible at small thickness of specimens. The thickness of structures can be increased without decreasing the quasioelectric field intensity when one uses multilayer structures or superlattices. In such structures, it is

possible to observe in the pronounced form of the manifestations of the quasioelectric field. Since the properties of graded-band-gap structures strongly depend on the shape of the energy band diagram, ascertainment of its peculiarities is the necessary and first stage at studying these structures. Firstly, the features of formation of the energy diagram of graded-band-gap superlattices were established in [5, 6] for the case of the symmetric form of the latter. These superlattices belong to those of a classical type [7–9] in which the superlattice's period is much greater than the de Broglie wavelength and therefore quantization of the energy spectra of electrons and holes does not take place. The aim of this research is to theoretically investigate the peculiarities of energy diagram of classical asymmetric graded-band-gap superlattices with linear coordinate dependences of band gap and electron affinity.

Methods

Constructing an energy band diagram means to plot coordinate dependences of conduction band bottom E_c and valence band ceiling E_v which are reckoned from

* Correspondence: b_sokolovsky@ukr.net
Department of Radioelectronic and Computer Systems, Faculty of Electronics and Computer Technologies, Ivan Franko National University of Lviv, 50 Dragomanov Street, 79005 Lviv, Ukraine

the vacuum level E_0 and expressed through the electrostatic energy $-e\phi$, the electron affinity χ and the band gap E_g :

$$E_c(x) = E_0 - e\phi(x) - \chi(x), \tag{1}$$

In this work, we will consider the sawtooth-like type of graded-band-gap superlattice in which E_g and χ are piecewise linear functions (Fig. 1).

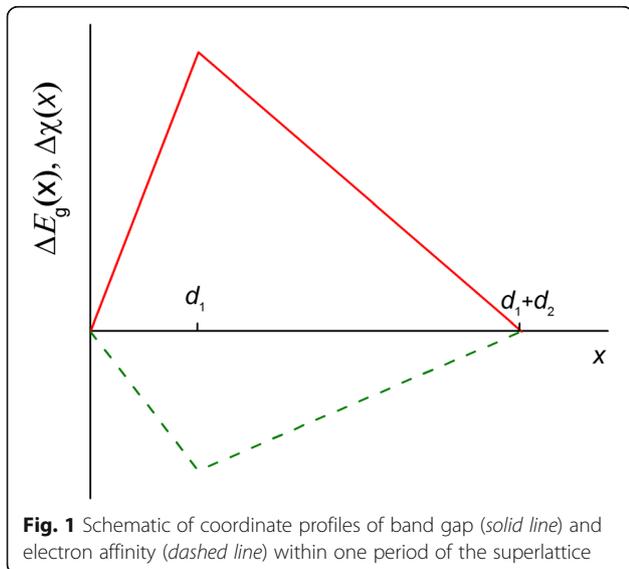
The coordinate dependence of electrostatic potential ϕ can be found from Poisson's equation

$$\varepsilon\varepsilon_0 \frac{d^2\phi}{dx^2} = e \left[N_c \exp\left(\frac{E_F - E_c(x)}{kT}\right) - N_v \exp\left(\frac{E_v(x) - E_F}{kT}\right) + N_a - N_d \right]. \tag{2}$$

In Eq. (2), written for the case of carrier nondegeneracy, ε and ε_0 represent the dielectric constants of the material and free space; N_c and N_v are the effective densities of states in the conduction and valence bands, N_a and N_d are the concentrations of acceptors and donors, and E_F is the constant Fermi level of the structure.

The electron, n , and hole, p , concentrations appearing in Eq. (2) can be written as follows:

$$n(x) = N_c \exp\left[\frac{\zeta(x)}{kT}\right] = n_0(0) \exp\left[\frac{e\phi + \Delta\chi(x)}{kT}\right], \tag{3}$$



$$p(x) = N_v \exp\left[-\frac{E_g(x) + \zeta(x)}{kT}\right] = p_0(0) \exp\left[-\frac{\Delta E_g(x) + \Delta\chi(x) + e\phi(x)}{kT}\right], \tag{4}$$

where $\zeta_0(x) = E_F - E_c(x)$, $\Delta E_g(x) = E_g(x) - E_g(0)$, $\Delta\chi(x) = \Delta\chi(x) - \Delta\chi(0)$, $n_0(0)$, and $p_0(0)$ are respectively the concentrations of electron and holes in an uniform semiconductor with the same composition (band gap) and doping level as in the graded-band-gap multilayer structure at the point $x=0$. From the neutrality equation, we have

$$n_0(0) = N_c \exp\left[\frac{\zeta_0(0)}{kT}\right], \tag{5}$$

$$p_0(0) = N_v \exp\left[-\frac{E_g(0) + \zeta_0(0)}{kT}\right] = \frac{n_i^2(0)}{n_0(0)}, \tag{6}$$

where $\zeta_0(0)$ is the value of function

$$\zeta_0(x) = kT \ln \left[\frac{N_d - N_a + \sqrt{(N_d - N_a)^2 + 4n_i^2(x)}}{2N_c} \right] \tag{7}$$

in the point $x=0$. Here, function $\zeta_0(x)$ has the meaning of difference between the Fermi level and conduction band bottom (i.e., chemical potential of electrons) in the uniform semiconductor with the parameters corresponding to the point x of our structure.

For the profiles of $E_g(x)$ and $\chi(x)$ presented in Fig. 1, Poisson's equation can be written in the following dimensionless form:

$$\frac{d^2\bar{\phi}}{d\xi^2} = (1-\kappa) \exp(\bar{\phi} + \beta\xi) - \kappa \exp[-\bar{\phi} - (\delta + \beta)\xi] + \bar{N} \tag{8}$$

at $0 \leq \xi < \bar{d}_1$ and

$$\frac{d^2\bar{\phi}}{d\xi^2} = (1-\kappa) \exp[\bar{\phi} - \beta[v(\xi - \bar{d}_1) + \bar{d}_1]] - \kappa \exp[-\bar{\phi} + (\delta + \beta)[v\xi - (v+1)\bar{d}_1]] + \bar{N} \tag{9}$$

at $\bar{d}_1 \leq \xi < \bar{d}_1 + \bar{d}_2$,

where $\bar{\phi} = e\phi/kT$, $\xi = x/L_D$, $L_D = \sqrt{\varepsilon\varepsilon_0 kT/e^2[n_0(0) + p_0(0)]}$, $\delta = (L_D/kT)dE_g/dx$ (at $x < d_1$), $\beta = (L_D/kT)d\chi/dx$ (at $x < d_1$), $\kappa = p_0(0)/[n_0(0) + p_0(0)]$, $v = d_1/d_2$, and $\bar{N} = (N_a - N_d)/[n_0(0) + p_0(0)]$.

Equations (8) and (9) should obey the following boundary conditions:

$$\begin{aligned} \bar{\varphi}(\xi = -\bar{d}_1) &= \bar{\varphi}(\xi = +\bar{d}_1), \bar{\varphi}(\xi = +0) \\ &= \bar{\varphi}(\xi = -\bar{d}_2), \end{aligned} \tag{10}$$

$$\begin{aligned} \frac{d\bar{\varphi}}{d\xi}(\xi = -\bar{d}_1) &= \frac{d\bar{\varphi}}{d\xi}(\xi = +\bar{d}_1), \frac{d\bar{\varphi}}{d\xi}(\xi = +0) \\ &= \frac{d\bar{\varphi}}{d\xi}(\xi = -\bar{d}_2), \end{aligned} \tag{11}$$

which reflect the continuity of electrostatic potential and electric field strength at the interfaces.

Results and Discussion

For obtaining the analytical solution of boundary problem (8)–(11), we consider the case when the drops in E_g and χ are small in comparison with $kT(|\Delta E_g(d_1)|) \ll kT$, $|\Delta\chi(d_1)| \ll kT$. Then, the right hand side of (8) and (9) can be linearized what allows us to obtain the following expressions for $E_c(\xi)$:

$$\begin{aligned} \frac{E_c(\xi) - E_c(0)}{kT} &= \kappa\delta\xi - (\nu + 1) \\ &\times (\beta + \kappa\delta) \frac{\sinh\left(\frac{\bar{d}_1}{2}\right) \sinh\left(\xi - \frac{\bar{d}_1}{2}\right)}{\sinh\left(\frac{\bar{d}_1 + \bar{d}_2}{2}\right)} \end{aligned} \tag{12}$$

at $0 \leq \xi < \bar{d}_1$,

$$\begin{aligned} \frac{E_c(\xi) - E_c(0)}{kT} &= -\nu\kappa\delta\xi + (\nu + 1) \\ &\times (\beta + \kappa\delta) \left[\frac{\exp\left(\frac{\bar{d}_1}{2}\right) \sinh\left(\frac{\bar{d}_1}{2}\right) \cosh\left(\xi - \frac{\bar{d}_1 + \bar{d}_2}{2}\right)}{\sinh\left(\frac{\bar{d}_1 + \bar{d}_2}{2}\right)} \right] \end{aligned} \tag{13}$$

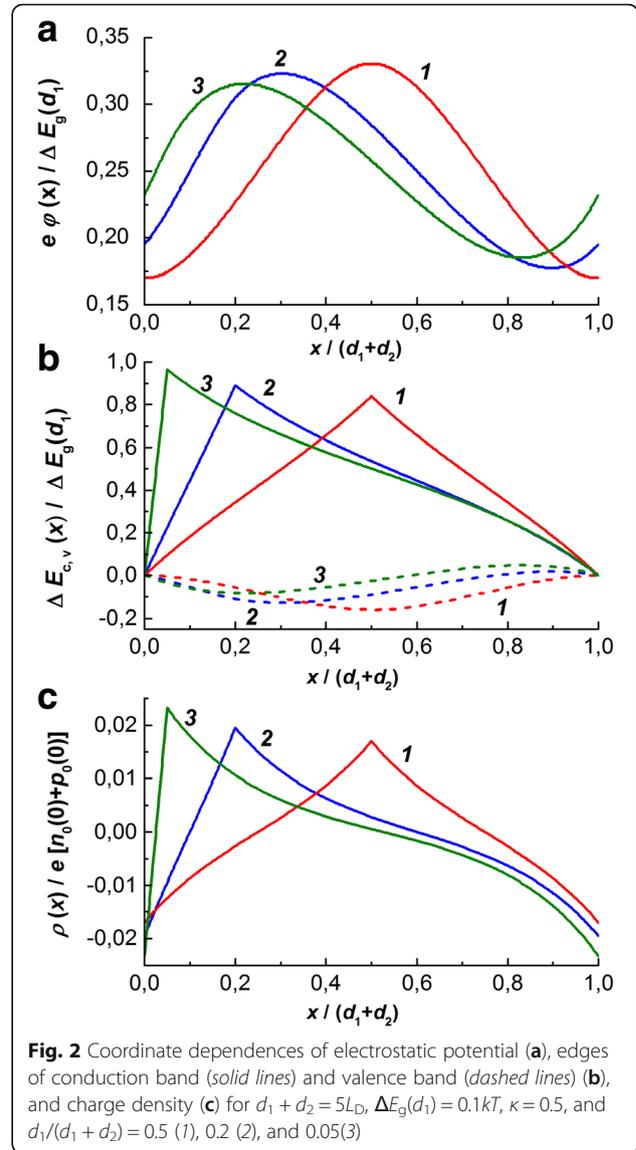
at $\bar{d}_1 \leq \xi < \bar{d}_2 + \bar{d}_1$.

Since $E_v(\xi) = E_c(\xi) - E_g(\xi)$, the above expressions allow one to calculate the coordinate dependences of the valence band ceiling.

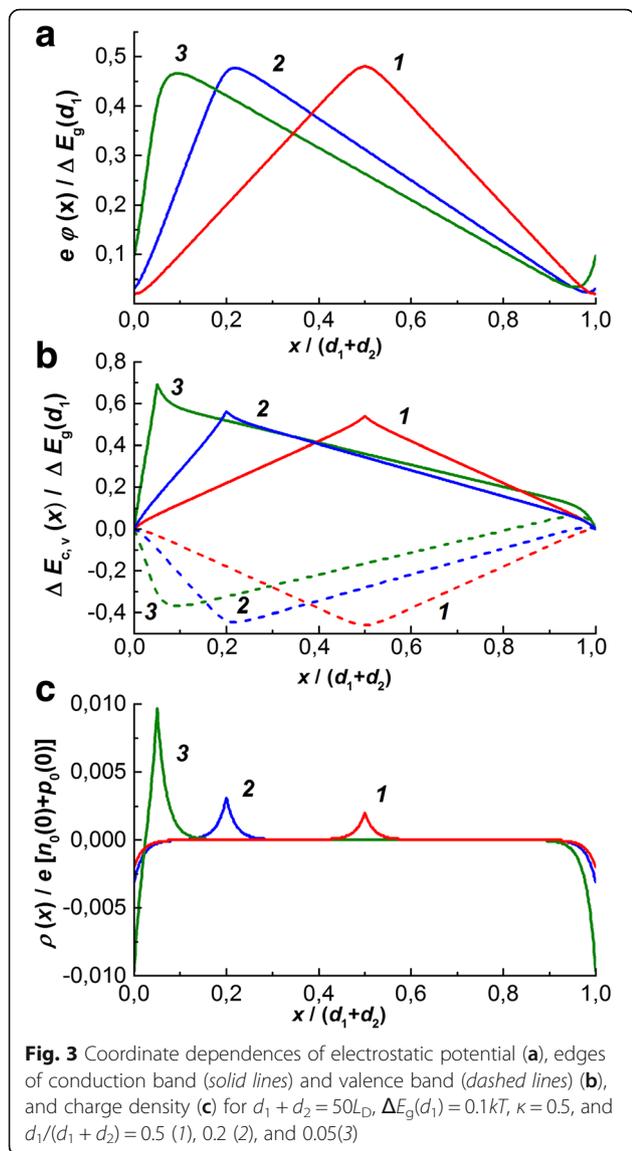
Let us analyze the general features of energy band diagram formation on the example of the simplified but quite realistic structure with intrinsic conductivity ($\kappa = 0.5$) in which the edge of valence band does not depend on the composition and therefore on the coordinate ($\beta + \delta = 0$). Such a “common anion rule” [10] is fulfilled in a number of solid solutions on the basis of A_2B_6 and A_3B_5 compounds.

The calculated dependences are shown in Figs. 2 and 3 for the cases of comparable and large period with respect to the Debye screening length.

It follows from the solution of Eqs. (8) and (9) that contrary to the case of symmetric superlattices [5, 6], the electrostatic potential in the asymmetric ones non-monotonously depends on the coordinate within the layer



of larger thickness (Figs. 2 and 3a) reaching there both minimum and maximum. These features are also manifested in the shape of the energy band diagram (Figs. 2 and 3b) especially in the case when the thickness of larger layer is of the order of the Debye length. Then, in two layers of the lattice’s period, the space charge is built up (Fig. 2c) with the integral electroneutrality being fulfilled within each layer. The charge of maximal density is located at the interfaces and its absolute value increases at increasing the degree of lattice asymmetry. When thickness of the lattice’s layer greatly exceeds the Debye length, the conduction and valence edges are characterized by the linear dependences in the whole volume for the exception of thin regions in the vicinity of interfaces (Fig. 3c).



For small values of the layer thickness ($d_1, d_2 \ll L_D$), the electrostatic potential nearly does not depend on the coordinate

$$\bar{\phi}(\xi) \cong \frac{\beta + \kappa\delta}{2}. \tag{14}$$

Therefore,

$$\Delta E_c(\xi) \cong \Delta\chi(\xi), \tag{15}$$

$$\Delta E_v(\xi) \cong \Delta\chi(\xi) - \Delta E_g(\xi), \tag{16}$$

i.e., the profiles of the band edges are determined only by the coordinate dependences of E_g and χ . Such a property is also observed in doped superlattices.

Conclusions

Charge carrier redistribution taking place in a sawtooth-like graded-band-gap superlattice leads to formation of energy band diagram which is characterized by the following features:

1. The shape of energy band diagram depends of the value of the superlattice’s period and the ratio of thicknesses of adjacent layers, with the most noticeable size dependence taking place when the superlattice’s period is of the order of the Debye length.
2. Contrary to the symmetric graded-band-gap superlattices, the extrema of conduction or valence band in the asymmetric superlattices are formed not at the interfaces but within the layer of larger thickness.
3. When the period of graded-band-gap superlattice is much smaller than the Debye length, the profiles of the band edges are determined exclusively by the coordinate dependences of band gap and electron affinity.

Authors’ Contributions

All the authors took part in solving the problem under the study. They read and approved the final manuscript.

Competing Interests

The authors declare that they have no competing interests.

Publisher’s Note

Springer Nature remains neutral with regard to jurisdictional claims in published maps and institutional affiliations.

Received: 29 December 2016 Accepted: 6 March 2017

Published online: 20 March 2017

References

1. Kröemer H (1957) Quasi-electric and quasi-magnetic fields in nonuniform semiconductors. *RCA Review* 18:332–342
2. Kröemer H (2001) Nobel lecture: quasidelectric fields and band offsets: teaching electrons new tricks. *Rev Mod Phys* 73(3):783–793
3. Langer F, Perl S, Höfling S, Kamp M (2015) Graded band gap GaInNAs solar cells. *Appl Phys Lett* 106(23): 10.1063/1.4922279.
4. Dharmadasa IM, Ojo AA, Salim HI, Dharmadasa R (2015) Next generation solar cells based on graded bandgap device structures utilising rod-type nano-materials. *Energies* 8(6):5440–5458
5. Savitskii VG, Sokolovskii BS (1994) Energy diagram of classical varigap superlattices. *Semiconductors* 28(2):217–219
6. Sokolovskii BS (1997) Multilayer structures based on doped graded-band-gap semiconductors: features of energy band diagram. *Phys Stat Sol (a)* 163(2):425–432
7. Capasso F, Tsang WT, Hutchinson AL, Williams GF (1982) Enhancement of electron impact ionization in a superlattice: a new avalanche photodiode with a large ionization rate ratio. *Appl Phys Lett* 40(1):38–40
8. Kozlovskii YY, Neustroev LN, Osipov VV (1990) Transverse photoconductivity of classical composition superlattices. *Phys Techn Semicond* 24(3):497–502
9. Bass FG, Bulgakov AA (1997) Kinetic and electrodynamic phenomena in classical and quantum semiconductor superlattices. Nova Science, New York
10. McCaldin JO, McGill TC, Mead CA (1976) Correlation for III-V and II-VI semiconductors of the Au Schottky barrier energy with anion electronegativity. *Phys Rev Lett* 36(1):56–58